

Spectroscopic Characterization of Miniaturized Atmospheric-Pressure dc Glow Discharge Generated in Contact with Flowing Small Size Liquid Cathode

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Received: 1 April 2011 / Accepted: 14 June 2011 / Published online: 1 July 2011
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Abstract The miniaturized atmospheric pressure glow discharge (APGD) generated between a solid electrode and a flowing small size liquid cathode (dimension 2 mm) was investigated here using optical emission spectroscopy. The discharge was studied in an open air atmosphere, and the spectral characteristics of the plasma source was examined. Analysed APGD was operated at a discharge voltage of 1,100–1,700 V, a discharge current of 20 mA and gaps between a solid anode and a liquid cathode in the range from 0.5 to 3.5 mm. The emission intensities of the main species were measured as a function of various experimental conditions, including the solution flow rate, the gap between the electrodes, and the concentration of hydrochloric acid. The excitation temperature, the vibrational temperatures calculated from N_2 , OH, and NO bands, and the rotational temperatures determined from band of OH, N_2 and NO, were found to be dependent on these experimental parameters. The electron number density was determined from the Stark broadening of H_β line. Additionally, the ionization temperature and degree were calculated using the Saha–Boltzmann equation, with the ion to atom ratio for magnesium ($MgII/MgI$). The results demonstrated that $T_{exc}(H)$, $T_{vib}(N_2)$, $T_{vib}(OH)$, $T_{vib}(NO)$ and $T_{rot}(OH)$ were well comparable ($\sim 3,800$ – $4,200$ K) for selected plasma generation conditions (gap ≥ 2.5 mm, HCl concentration ≥ 0.1 mol L^{-1}), while the rotational temperatures determined from band of N_2 ($\sim 1,700$ – $2,100$ K) and band of NO ($\sim 3,000$ K) were considerably lower. The electron number density was evaluated to be $(3.4$ – $6.8) \times 10^{20}$ m^{-3} and the ionization temperature varied, throughout in the 4,900–5,200 K range.

Keywords Atmospheric pressure glow discharge · Optical emission spectrometry · Plasma diagnostics · Liquid cathode · Miniaturized plasma source

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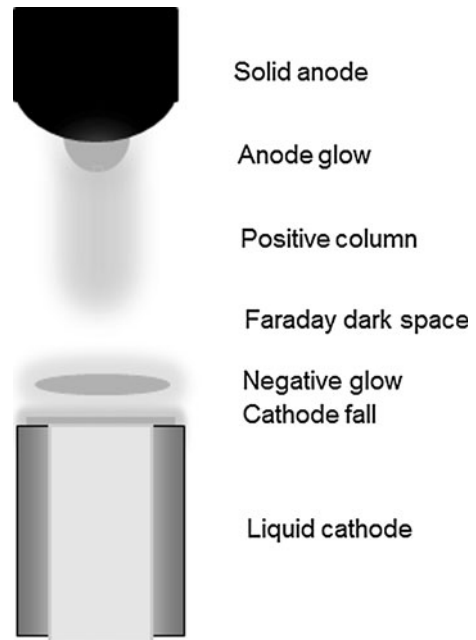
Introduction

Atmospheric pressure glow discharges (APGD's) generated in contact with liquid are of great importance due to their potential applications in analytical spectrometry [1–5] as compact and low operating cost atomic emission micro-sources. These plasma sources may be also applied to the production of special kinds of materials (coatings, nanoparticles, etc.) [6, 7], to surface modification [7], to the purification of waste water from organic compounds [8–10], and to water sterilization [8, 9].

Usually the generation of the APGD between a solid anode and a liquid cathode requires application of a dc high voltage [10–14]. Stable APGDs with liquid electrodes have been generated by applying voltages between 0.4 and 1.8 kV and currents between 5 and 150 mA, over gaps ranging from 0.2 to 5 mm in the air atmosphere [7, 15, 17, 18]. On the other hand, by using a miniature argon or helium gas flow instead of a solid rod anode, stable glow discharge has been observed for gaps of up to 20 mm between the anode and the liquid cathode [17]. Stable APGD was also generated in other gas atmospheres like N₂, N₂O, CO₂ [15].

Recently, APGD plasmas with various liquid electrodes have been studied at different currents and distances from the liquid electrode [11–26], while the other plasma generation parameters were faintly investigated. Nevertheless, the phenomena of glow discharge generated at atmospheric pressure are still poorly understood. The emission and electrical properties of atmospheric pressure glow discharges generated between a metal pin electrode and surface of tap water (working as a cathode or anode) were investigated by Bruggeman et al. [11] as a function of discharge current (7.5–30 mA) and of distance from the cathode liquid surface. A cathode fall, a negative glow, a Faraday dark space, a positive column and an anode glow were identified in the discharge for the liquid electrode—pin electrode system [11, 14, 21] (Fig. 1). Additionally, Bruggeman et al. [11] found that rotational temperatures of N₂ and OH were identical and equal to 3,250 K in the anode glow region (positive column). The cathode voltage drop, the electric field strength, and the vibrational and rotational temperatures of N₂ were studied by Titov et al. [12, 13] as a function of discharge current (10–50 mA) for distilled water and for aqueous solutions of HNO₃, KCl, KBr and KI. The plasma parameters, i.e., the vibrational and rotational temperatures of N₂ (~4,200 and ~2,100 K, respectively), indicated that this atmospheric pressure glow discharge was a non-equilibrium system. The spatial distribution of the OH rotational temperature (4,000–8,000 K), the Cu excitation temperature (5,500–7,500 K) and the OH and N₂ species emission intensities were reported by Cservalvi et al. in an electrolyte cathode—solid anode discharge (ELCAD) source [14]. In other work, enhanced metal emission intensities were observed in a liquid cathode containing hydrochloric acid [24]. The Fe excitation temperature and the OH rotational temperature as well as emission intensities of the main species were investigated by Webb et al. [2, 25] as a function of distance from the liquid cathode. Maximum temperatures and emission intensities were observed near the cathode region. Recently, Bruggeman et al. [22] reported the rotational temperatures of OH and N₂, the electron number density and the H excitation temperature achieved using distilled water and a solution of NaOH and NaCl as liquid cathodes. These parameters were studied as a function of the discharge current, the solution conductivity and the distance from the cathode. The OH rotational temperature (3,200–3,750 K) was higher than the N₂ rotational temperature (2,500–2,750 K), while the electron number density and the H excitation temperature were $(5.5–8.0) \times 10^{14} \text{ cm}^{-3}$ and 5,750–7,250 K, respectively. Concentrations of OH radicals and the OH rotational temperature were measured Nikiforov et al. [26] as a function of discharge current, by means of laser induced

Fig. 1 The schematic diagram of APGD generated in contact with *liquid* cathode



fluorescence (LIF) technique. They found that OH rotational temperature was in the range 2,850–3,250 K, while the concentrations of OH were relative high (10^{21} – 10^{22} m⁻³).

The main aim of this work was the spectroscopic characterization of miniaturized plasma source operated in an open air atmosphere between solid anode and a new construction of liquid cathode. As a small size liquid cathode the solution of hydrochloric acid spiked with Mg ions was applied. Various plasma parameters were measured at different experimental conditions. Investigated plasma parameters included the ionization, excitation, vibrational and rotational temperatures derived from various species, as well as electron number density. Experimental variables were the flow ratio of solution, the gap between electrodes, and the concentration of hydrochloric acid. In addition, we investigated the plasma equilibrium. Additionally, the range of plasma stability was described. It was found, that it is possible to generate stable plasma with flow of electrolyte and without, i.e., between solid anode and graphite tube. Advantageously, in this work a stable micro glow discharge was obtained at a lower solution uptake (0.6 mL min⁻¹) than it has usually been reported in previous studies.

Experimental Set-Up

A schematic diagram of the experimental setup is presented Fig. 2. The construction of the plasma device developed and used here was quite different from this described by Cservalvi et al. [14, 24] and Webb et al. [2, 25]. In the construction proposed by these authors the electrolyte solution was introduced to the plasma by means of quartz tube and the overflow electrolyte from quartz tube (thin films of electrolyte on the outer parts of quartz tube) served as an electrical connection between plasma and the solution in the reservoir and consequently with the electrode. According to Mezei et al. [5], such the

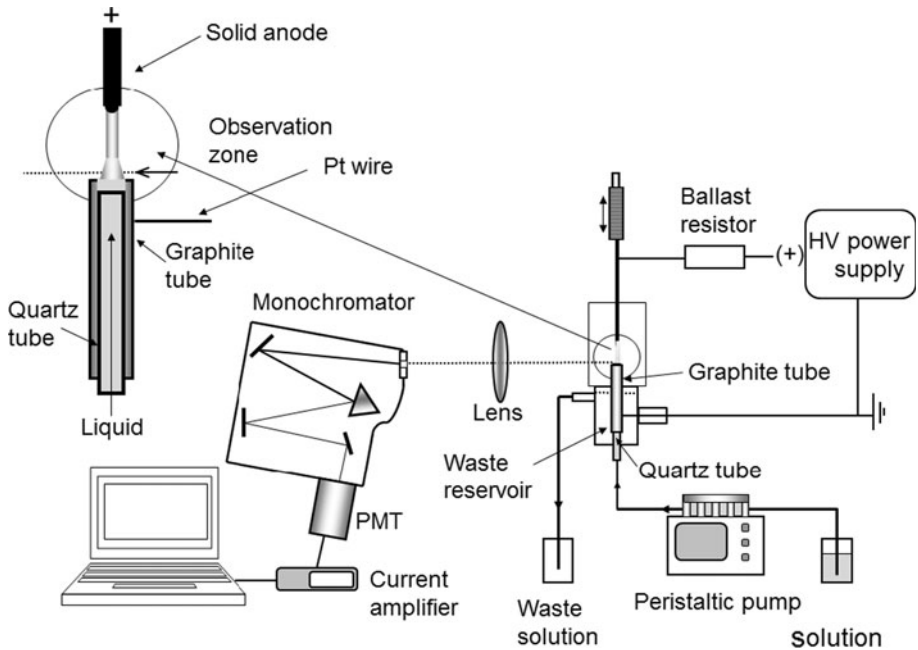


Fig. 2 The experimental setup (not to scale)

liquid cathode needed the higher flow rate of solutions in order to maintain electrical contact with electrode and plasma, and in consequence it did not work properly without flowing solution. Additionally, higher current was necessary and these devices could be more sensitive to instabilities for instance a presence of gases in the solution.

In the plasma device construction developed by us, the glow discharge was generated between a molybdenum rod anode and a small size flowing liquid cathode in an open air atmosphere. In order to improve the electrical contact with the electrolyte solution, an additional graphite tube was applied (Fig. 2). At the top of the graphite tube (4 mm) it was encountered with the electrolyte. In contrast with other studies described in a recent review paper [5], we found that a lower sample uptake (range of flow rates from 0.60 to 3.20 mL min^{-1}) was required to maintain a stable glow discharge at atmospheric pressure. It was also possible generate stable plasma without liquid flow, i.e., between solid anode and graphite tube. This plasma device construction proposed here is considerably less sensitive for any instabilities and interferences than the former devices.

The discharge was powered by a dc high voltage power supply. A positive potential was supplied to the anode, while a grounded platinum wire was used to make electrical contact with the graphite tube and consequently with the electrolyte. A discharge current equal to 20 mA was used for all experiments. A $20 \text{ k}\Omega$ ballast resistor was connected to the anode positive output to stabilize the discharge current. The distance between the anode and the cathode was adjusted using a micrometer screw attached to the solid anode. As an electrolyte, the solution of HCl spiked with Mg ions was applied. The liquid sample was introduced into the plasma zone through a quartz-graphite tube, with an inner diameter of 2 mm , using a Jobin–Yvon peristaltic pump. The diameter of graphite tube was limited the

Table 1 Experimental conditions

Type of discharge	dc-APGD
Current	20 mA
Voltage	1,100–1,700 V
Ballast resistor	20 k Ω
Atmosphere/pressure	Open air/atmospheric pressure
Gap between electrodes	0.5–4.0 mm
Electrolyte flow rate	0.60–3.2 mL min ⁻¹
Liquid cathode	Solution of HCl, spiked with Mg ions, maximum diameter 2 mm

dimension of cathode and consequently the plasma dimension. Working solution of Mg ions (10 $\mu\text{g mL}^{-1}$) was prepared from a single stock solution (Merck, 1,000 $\mu\text{g mL}^{-1}$) by dilution with twice-distilled water. The aqueous Mg solutions were acidized using hydrochloric acid (HCl, POCH Gliwice, analytical grade). The addition of HCl was necessary to improve the solution conductivity. The HCl concentrations varied from 0.01 to 1.0 mol L⁻¹. The solution overflows from the quartz-graphite tube was collected in the waste reservoir. A summary of the experimental plasma excitation conditions is shown in Table 1.

A JY TRIAX 320 scanning monochromator (grating 1,200 grooves mm⁻¹, blazed at 250 nm) was used with a Hamamatsu R-928 photomultiplier biased at -700 V, to measure the emission coming from the plasma over the range from 200 to 850 nm. The output signal of the photomultiplier was amplified using a JY SpecAcq2 system. The SpectraMax/32 software was used for data processing and collecting. Plasma emission was measured near the liquid cathode region. A quartz achromatic lens ($f = 75.6$, diameter 2") was used to project the plasma radiation onto the entrance slit of the monochromator. Calibration of the whole optical system was undertaken with a CL2 halogen lamp (Bentham), working at 8.5 A, 17.2 V, with a known spectral emissivity (Protection Engineering Ltd. certificate of radiation).

Experimental Results and Discussion

Emission Spectra of Atmospheric Pressure dc Glow Discharge

Over all experimental conditions, spectra emitted by the atmospheric pressure dc glow discharge consisted of molecular bands of OH, N₂, NH and NO (see Fig. 3a–c), and atomic lines of hydrogen (H α , H β) and oxygen O I. The hydrogen line, H γ at 434.14 nm, was not clearly distinguished due to the overlapping by the band of N₂ (0–4) with the bandhead at 434.36 nm. Details of the molecular and atomic species identified as well as their excitation energies are presented in Table 2.

The spectral lines resulted from excitation processes of species originating either from the saturated water vapour and/or from the surrounding air atmosphere. If the water in the system was replaced by a solution containing Mg ions, additionally strong atomic line of the Mg I at 285.21 nm, was observed. We also detected and measured weak lines of ionized magnesium, i.e., Mg II at 279.55 nm and Mg II at 280.257 nm (see Fig. 2b). As can be seen in the Table 2, the maximum energy of excited states of species was up to 13 eV.

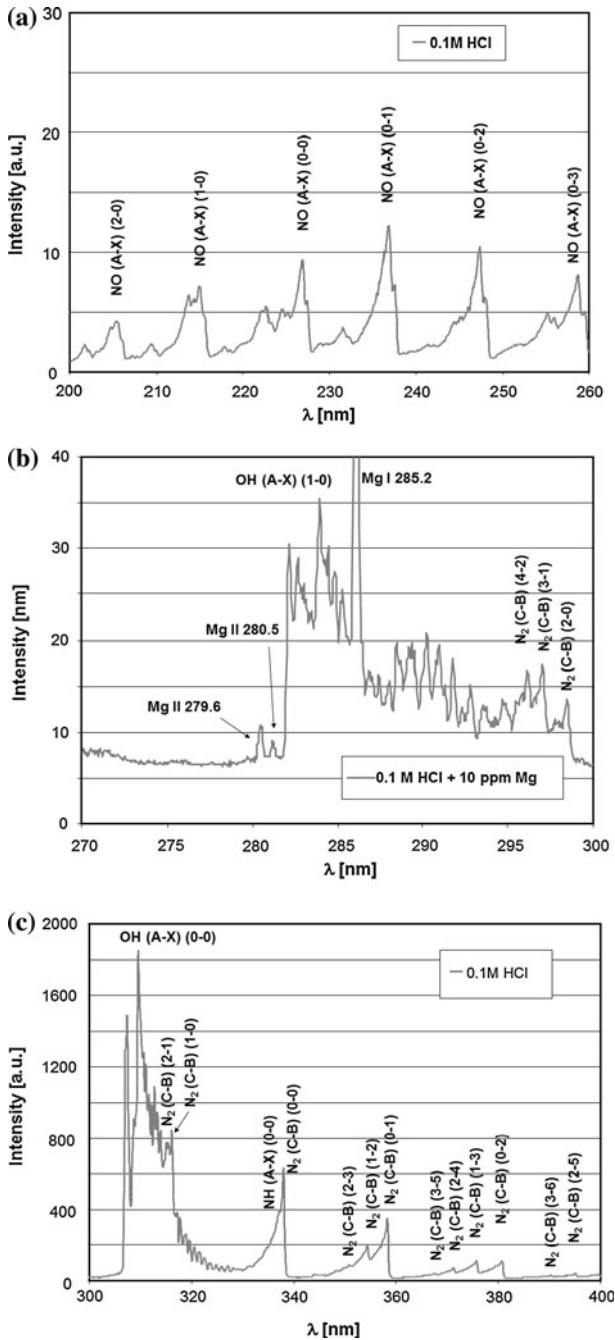


Fig. 3 The emission spectrum of APGD over the range **a** 200–260 nm, **b** 270–300 nm and **c** 300–400 nm (0.1 M HCl spiked with 10 ppm Mg ions)

Table 2 Atomic and molecular species identified in the region near the liquid cathode

Species	Emission spectra	Excitation energy
N ₂	Numerous bands of the C ³ Π _u –B ³ Π _g system	~ 11.2–11.9 eV
OH	Bands of the A ² Σ–X ² Π system (0–0) (1–0) (2–0)	~ 4.1 eV
NO	Numerous bands of the γ-system (A ² Σ ⁺ –X ² Π)	~ 5.5–6.5 eV
NH	Band of the A ³ Π–X ³ Σ [–] system (0–0) at 336.0 nm	~ 3.7 eV
H	Lines at 486.1 nm (H _β) and 656.2 nm (H _α)	12.74 eV; 12.09 eV
O I	Lines at 777.2 and 844.6 nm	10.74; 10.99 eV
Mg I	Line at 285.21 nm	4.34 eV
Mg II	Lines at 279.55 and 280.26 nm	12.07 eV

The presence of magnesium atoms (or ions) in the plasma zone can be attributed to plasma sputtering of the water surface, similarly to the plasma sputtering processes in low pressure glow discharge, according to [18, 19]. Generally, emission intensities of atomic and ionic Mg lines decreased with lowering concentration of HCl in solution. By contrast, the decrease of HCl concentration in solution (and consequently, the decrease of the solution conductivity) caused the increase of the burning voltage from 1,300 to 1,700 V. A similar dependence was noted by Mezei et al. in a ELCAD source [5]. At the HCl concentration of 0.01 mol L⁻¹, the Mg atomic spectral line was very weak and the Mg II lines were not excited. A similar effect was also observed by Cserfalvi and Mezei [18], who also observed the metal atomic lines when the solution pH was higher than 2.5. In this work, the emission ion to atom ratio for Mg (MgII/MgI) was found to be between 0.027 and 0.080. It is two orders of magnitude lower than in the inductively coupled plasma (ICP) source working at atmospheric pressure [27]. The maximum value of the ion to atom ratio for Mg, (0.080), was observed using a solution containing 1.0 mol L⁻¹ HCl.

In contrast to others reports on emission spectra of APGD plasmas generated using significantly higher currents and slightly lower voltage [11, 25], we did not observe any molecular bands of N₂⁺ or any ionic lines of oxygen (O II) in the near cathode region. The excited states of ionized molecular nitrogen (N₂⁺) and ionized oxygen (O⁺) require threshold energies of approximately ~18 and ~25–35 eV, respectively. Anyway, these values seem to be large compared with the energies of electrons or other high energy species present in glow discharge plasmas at atmospheric pressure [5, 13].

The Behavior of Active Plasma Species

Emission from plasma was monitored versus experimental parameters, including solution flow rate, gap size (length of separation between the solid anode and the liquid cathode) and the HCl concentration in solution.

The emission intensities of OH (head band at 309.5 nm), N₂ (head band at 337.1 nm), H_β (line at 486.1 nm), O I (line at 777.2 nm) and Mg I (line at 285.2 nm) were chosen as representatives to investigate the behavior of active plasma components. The emission of these species as a function of the size of the gap between the cathode and anode was shown in Fig. 4a. The distance between the solid anode and the liquid water surface (working as a cathode) was changed from 0.5 to 3.5 mm. Outside of this range, for gaps greater than 4.0 mm or less than 0.5 mm, the discharge was unstable and was therefore not investigated. Generally, intensities of OH, N₂ and H increased with the gap size and maximum

intensities were observed at the gap of 2.5 mm. For the 2.5 mm gap, the volume of plasma and the diameter of the cathode spot were estimated to be $\sim 6 \mu\text{L}$ and $\sim 1.5 \text{ mm}$, respectively. The growth in distance between the solid anode and the liquid cathode required a commensurate increase in applied voltage, from 1,100 to 1,700 V, changing the discharge power from 22 to 34 Watts. In contrast, the Mg I intensity decreased with an increasing gap between the electrodes (Fig. 4a). It was probably associated with the spreading of desolvated Mg atoms as the distance between electrodes grew. For small gap sizes (0.5–1.0 mm) only the negative glow was visible. The positive column appeared and grew for gaps larger than 1.5 mm. Usually, the emission of the metal lines was the strongest in the near cathode region (negative glow), but weak metal intensities were also observed in the near anode region, i.e., in the positive column [25].

Raising the solution flow rate from 0.60 to 3.2 mL min^{-1} led to a linear increase in the emission intensities of OH, H, O and N_2 species (Fig. 4b), while the intensity of the Mg I line decreased and was lowest for solution flow rates of 1.9 – 2.3 mL min^{-1} . A similar effect was also observed by Shaltout [3] for the Ca I emission line in a dc microplasma source, generated at the following conditions: current 20–80 mA, voltage 500 V, gap 0.5–2 mm. The decrease in the Mg I emission along with growing solution flow rate may also be a consequence of additional water vaporization. The presence of additional water (or products coming from water) may reduce the energy and number of free electrons responsible for the excitation of Mg atoms.

Intensities of the main species were also monitored as a function of HCl concentration. The intensities of OH, N_2 , Mg I and O I increased with the growth of the HCl concentration, while the emission intensity of the H emission line changed in a different manner (Fig. 4c). The dissociation of water vapour ($\text{H}_2\text{O} + e = \text{OH} + \text{H} + e$) and dissociative recombination of H_2O^+ ions ($\text{H}_2\text{O}^+ + e = \text{OH} + \text{H}$) were found to be the dominant processes for the production of H and OH species in the central part of the plasma [5]. However, the difference in behavior of the OH and H emission intensities as a function of experimental conditions can be treated as evidence for the presence of a multichannel process in the region near the liquid cathode. The excited state of nitrogen, $\text{N}_2(\text{C})$, was produced by electron impact excitation of nitrogen in the surrounding air. In contrast, a stepwise reaction consisting of the dissociation of molecular oxygen followed by electron impact excitation of oxygen atoms was probably the main mechanism responsible for producing excited states of atomic oxygen [13]. An alternative process, dissociative excitation of water by electron impact resulting in excited states of O, seems to be unlikely

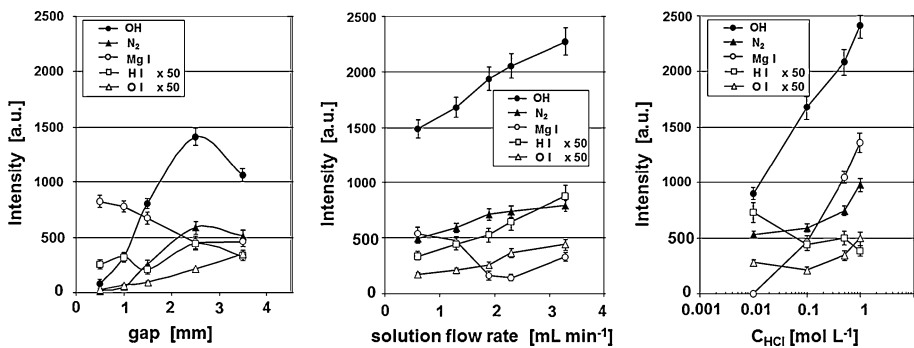


Fig. 4 The intensities of OH, N_2 , Mg, H, and O versus the length of the gap between the *solid* anode and the *liquid* cathode, the solution flow rate, and the concentration of HCl in solution

due to very high energy thresholds (17.6 eV) [11]. The growth of Mg I intensity with HCl concentration is probably due to an enhanced sputtering rates of the liquid cathode at higher HCl solution concentrations.

Plasma Parameters

Plasma temperatures, i.e., the ionization, excitation, vibrational, and rotational temperatures, and electron number density are very important parameters for description of a plasma source. The plasma temperatures of different species, permit a characterization of plasma equilibrium phenomena. Additionally, knowledge of the electron number density plays an important role in understanding the processes (excitation, ionization, etc.), which exist in a plasma source.

The Excitation, Vibrational and Rotational Temperatures in the APGD Source

The excitation temperature (T_{exc}) was determined using the two-line intensity ratio method [22]. Two prominent lines of hydrogen: H_α at 656.28 nm and H_β at 486.13 nm were applied. The vibrational temperature determined from N_2 and NO bands [$T_{vib}(N_2)$, $T_{vib}(NO)$] were calculated by the Boltzmann plot method. For N_2 , the four bands of the $C^3\Pi_u-B^3\Pi_g$ system, i.e., (0–2); (1–3); (2–4); (3–5), were used. For NO, the (0–0); (1–0) and (2–0) bands of $A^2\Sigma^+-X^2\Pi$ system, were employed. The linearity of the Boltzmann plot (see Fig. 5) indicates that the vibrational levels of N_2 follow the Boltzmann distribution. A similar dependence was observed for the vibrational levels of NO.

The monochromator resolution was low therefore, the rotational temperatures (T_{rot}) were determined from the unresolved rotational structures of OH ($A^2\Sigma^+$, $v' = 0 \rightarrow X^2\Pi$;

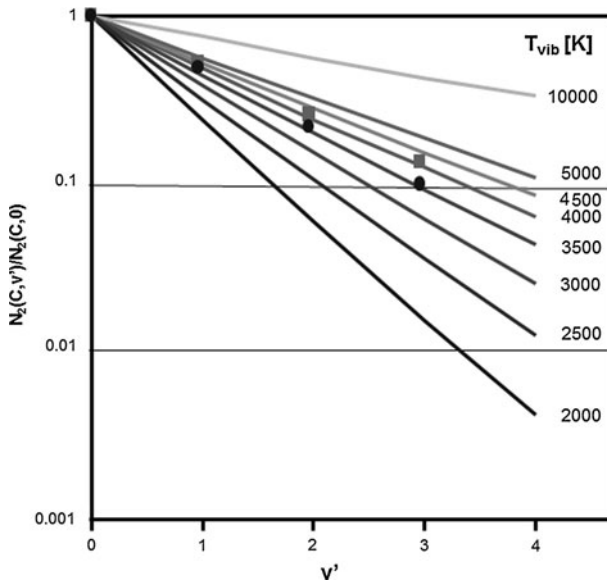


Fig. 5 The distribution of the $N_2(C, v')$ population normalized to the $N_2(C, 0)$ population, over vibrational temperatures ranging from 2,000 to 10,000 K, for solution uptake values of 0.6 mL min⁻¹ (circles) and 1.9 mL min⁻¹ (squares) using 0.1 mol L⁻¹ HCl

$v'' = 0$, in the range 306–310 nm), N_2 ($C^3\Pi_u$, $v' = 0 \rightarrow B^3\Pi_g$; $v'' = 2$, in the range 376–380 nm) and NO ($A^2\Sigma^+$, $v' = 0 \rightarrow X^2\Pi$; $v'' = 1$, in the range 232–237 nm) by comparison between experimental and simulated spectra method. In the case of OH only the lower rotational levels were taken into account. The rotational temperature was often determined by means of low resolution emission spectra of OH band (e.g., [11, 14]). The shape of unresolved parts of OH spectra in the range 306–310 nm is sensitive to plasma temperature variations and thus may be used for the temperature determination. A similar dependence was observed in case of N_2 and NO bands. The LIFBASE [28] and SpecAir [29] computer programs were applied to simulate the emission band spectra of OH (A–X), N_2 (C–B) and NO (A–X) for various rotational temperatures. A similar procedure was also applied to estimate the vibrational temperature determined from bands of OH. The spectra of two bands of OH, (0–0) and (1–0) were simulated at various vibrational temperatures and compared with experimental data. The spectroscopic constants of H, Mg I, and Mg II were taken from the NIST Atomic Spectra Database [30]. For molecular N_2 , the spectroscopic constants were obtained from tables as reported by Lofthus et al. [31]. The uncertainties of the temperature measurements were calculated to be ~ 15 , 2–10, 2–8 and 2–10% for the $T_{exc}(H)$, $T_{vib}(N_2)$, $T_{vib}(NO)$, and rotational temperatures respectively. Excitation, vibrational and rotational temperatures were measured as a function of the solution flow rate, the electrode gap size and the HCl concentration (Figs. 6, 7, 8).

As shown in Fig. 5, an increase of solution flow rate from 0.6 to 3.2 mL min⁻¹ resulted in a growth of temperatures. The vibrational temperature determined from N_2 bands changed from 3,400 to 4,600 K and the excitation temperature from 3,900 to 4,300 K. The $T_{rot}(OH)$ and $T_{rot}(N_2)$ depended slightly on the solution flow rate and varied from 3,600 to 4,000 K and 1,900–2,100 K, respectively (Fig. 6). The maximum values of the vibrational and excitation temperatures ($\sim 4,200$ K) were obtained for a gap equal to 1.5 mm (Fig. 7). For small gap sizes (0.5–1 mm) the excitation, vibrational and rotational temperatures

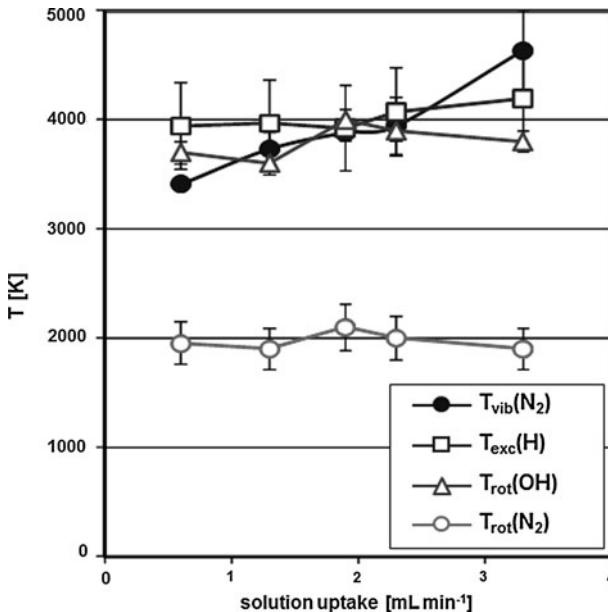


Fig. 6 The excitation, vibrational and rotational temperatures as a function of solution flow rate

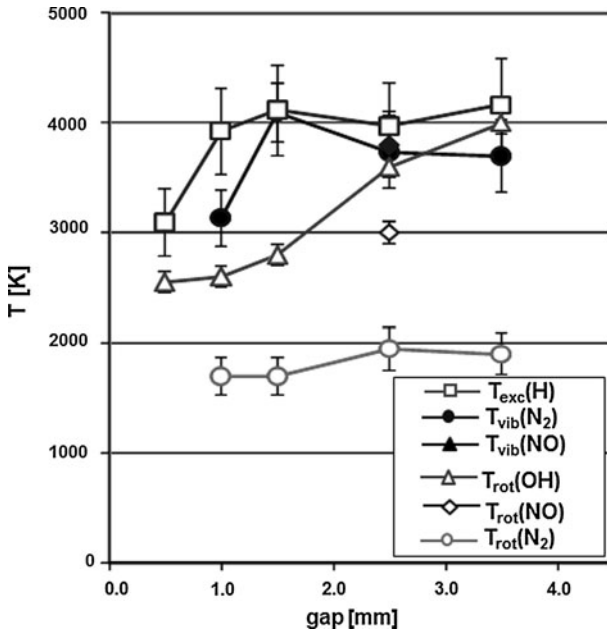


Fig. 7 Changes in the excitation, vibrational and rotational temperatures as a function of the size of the gap between the *solid* anode and the *liquid* cathode ($0.1 \text{ mol L}^{-1} \text{ HCl}$)

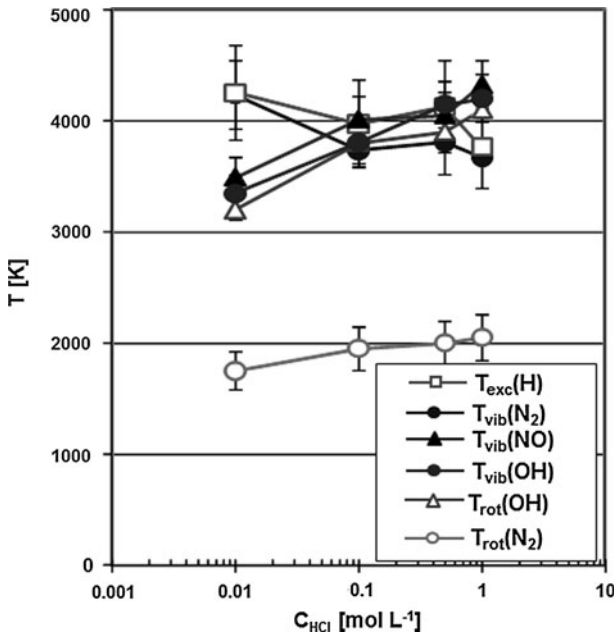


Fig. 8 The influence of HCl concentration on the plasma species temperatures

were the lowest. The increase in the gap between electrodes caused a growth in these temperatures. The most significant change was noted for $T_{\text{rot}}(\text{OH})$, namely from 2,700 to 4,000 K. This was probably associated with an increase of the discharge power from 22 to 34 Watts, especially taking into account that water vapour is a carrier medium. A similar effect was observed by Webb et al. [25] for the rotational temperature (from 2,700 to 3,200 K). The gap size only slightly affected the $T_{\text{rot}}(\text{N}_2)$ (changes in the range $\sim 1,700$ – $1,900$ K). Differences in the rotational temperatures indicate that mechanisms of the excitation process of these molecules are different. Changing the HCl concentration from 0.01 to 1 mol L⁻¹ caused the $T_{\text{rot}}(\text{OH})$ and $T_{\text{rot}}(\text{N}_2)$ increase from 3,200 to 4,100 K and from 1,700 to 2,100 K, as shown in Fig. 8, respectively. For the HCl concentrations ranging from 0.1 to 1.0 M, the excitation temperature and the vibrational temperatures as well as the rotational temperature determined from OH band were nearly equivalent ($\sim 3,800$ – $4,200$ K), while for the solutions containing 0.01 M HCl, the $T_{\text{exc}}(\text{H})$ and $T_{\text{vib}}(\text{N}_2)$ temperatures ($\sim 4,300$ K) were higher than the $T_{\text{rot}}(\text{OH})$, $T_{\text{vib}}(\text{NO})$ and $T_{\text{rot}}(\text{OH})$ temperatures (3,300–3,500 K; Fig. 8).

Generally, the rotational temperatures determined from OH and N₂ band changed in the range from 2,700 to 4,100 K and from 1,700 to 2,100 K, respectively. Comparable values of the rotational temperatures were noted by Bruggeman et al. [11, 22] in the region near the liquid cathode. Similar rotational temperature determined from band of OH was also measured Nikiforov et al. [26] by LIF and Webb et al. [25] by optical emission spectroscopy (OES) techniques. The vibrational temperature and excitation temperature were consistent with the previous studies [12, 22]. Throughout all experiments, the $T_{\text{rot}}(\text{N}_2)$ was considerably lower than the $T_{\text{rot}}(\text{OH})$. The difference between these temperatures ranged from 1,000 to 2,100 K. Nevertheless, a relatively good linear correlation ($R^2 = 0.85$) was found between $T_{\text{rot}}(\text{OH})$ and $T_{\text{rot}}(\text{N}_2)$. The rotational temperature calculated from band of NO was equal to $\sim 3,000$ K and was slightly dependent on experimental conditions. It was always observed that $T_{\text{rot}}(\text{OH}) > T_{\text{rot}}(\text{NO}) > T_{\text{rot}}(\text{N}_2)$. It can be explained by fact that APGD, generated in contact with liquid cathode, mainly operates in saturated water vapour, which contains H₂O⁺ ions [5] and nitrogen diffuses into the plasma from surrounding air [14] and thus may be excited in the “colder” part of plasma outside the central part (core of the glow discharge). The presence of NO in the plasma is probably due to the reaction of high energy states of nitrogen with oxygen [10]. The residual energy from excitation of N₂ may be converted into additional rotational energy of NO and thus the $T_{\text{rot}}(\text{NO})$ may be higher than $T_{\text{rot}}(\text{N}_2)$. The good correlation between $T_{\text{rot}}(\text{N}_2)$ and $T_{\text{rot}}(\text{OH})$ may also indicate that heat transfer from central parts of plasma (core of glow discharge) to “colder” parts can play an important role in the distributions of rotational temperatures in the near cathode region.

Generally, within the uncertainties of the temperature measurements, the vibrational temperatures measured in this work were equilibrated, that is, $T_{\text{vib}}(\text{N}_2) \approx T_{\text{vib}}(\text{OH}) \approx T_{\text{vib}}(\text{NO})$ for electrode gaps larger than 2.5 mm and HCl concentrations larger than 0.1 mol L⁻¹. The rotational temperature determined from band of OH was consistent with the vibrational temperature calculated from bands of OH but differed considerably from $T_{\text{rot}}(\text{NO})$ and $T_{\text{rot}}(\text{N}_2)$. Finally, for HCl concentrations in the range 0.1–1.0 mol L⁻¹ and for gaps ≥ 2.5 mm, the relations between the measured temperatures are as follows (see e.g., Fig. 9):

$$T_{\text{exc}}(\text{H}) \approx T_{\text{vib}}(\text{N}_2) \approx T_{\text{vib}}(\text{OH}) \approx T_{\text{vib}}(\text{NO}) \approx T_{\text{rot}}(\text{OH}) > T_{\text{rot}}(\text{NO}) > T_{\text{rot}}(\text{N}_2)$$

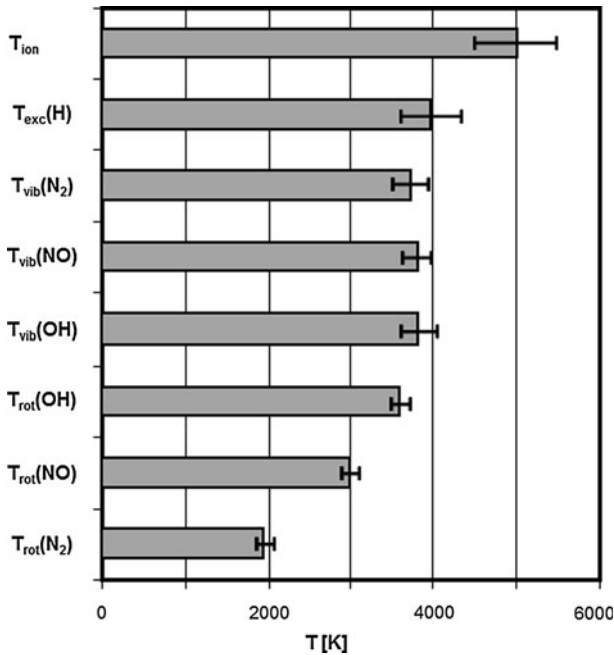


Fig. 9 The distribution of T_{ion} , $T_{exc}(H)$, $T_{vib}(N_2)$, $T_{vib}(NO)$, $T_{vib}(OH)$, $T_{rot}(OH)$, $T_{rot}(NO)$ and $T_{rot}(N_2)$ for a gap of 2.5 mm (0.1 M HCl, solution uptake 1.3 mL min⁻¹)

The Electron Number Density, Ionization Temperature and Ionization Degree

Electron number density was calculated using the Stark broadening of the H_β line (at 486.13 nm), employing the following equation, given by Gigososa et al. [32]:

$$(\lambda_s/4.800) = (n_e/10^{23})^{0.68116} \tag{1}$$

where λ_s is the full width at half maximum (FWHM) in nm and n_e is the electron number density in m⁻³.

The experimental profile of the H_β line was fitted using the Voigt algorithm, for deconvolution of a Lorentzian and a Gaussian line profile. This was done using the Galactic Grams/32 computer program. In order to measure the Stark broadening precisely, the H_β half width was corrected to account for Van der Waals broadening [22]. Based on the standard deviation, the uncertainty of n_e was estimated to be up to 10%.

The APGD plasma is not in the equilibrium state. However, at the assumption of the partial LTE state, the ionization temperature may be evaluated for the investigated plasma using the Boltzmann-Saha equation. A similar procedure was recently applied for the determination of the ionization temperature in atmospheric pressure glow discharges generated in air [20] and He [33], and an atmospheric pressure ICP [27, 34].

The ionization temperature (T_{ion}) was determined from the Boltzmann-Saha equation, using the ion to atom emission ratio for magnesium, Mg(II)/Mg(I) [27]:

$$\left(\frac{I_i}{I_a}\right) = \left(\frac{g_i A_i \lambda_a}{g_a A_a \lambda_i}\right) \left(\frac{2(2\pi m_e k T_{ion})^{3/2}}{n_e h^3}\right) \exp\left(-\frac{E_{ion} + E_i - E_a}{k T_{ion}}\right). \tag{2}$$

Table 3 Spectroscopic constant of Mg lines applied for the determination of the ionization temperature and degree of ionization [30]

Lines	λ (nm)	g_i	g_j	A_{ji} (10^8 s^{-1})	E (eV)	E_{ion} (eV)
Mg II	279.55	2	4	2.60	4.434	7.646
Mg I	285.21	1	3	4.91	4.346	

here I is the line intensity, g is the statistical weight, A is the transition probability, λ is the line wavelength, E is the energy of the excited state, and E_{ion} is the ionization potential. Subscripts “ i ” and “ a ” refer to parameters for an ion and an atom, respectively.

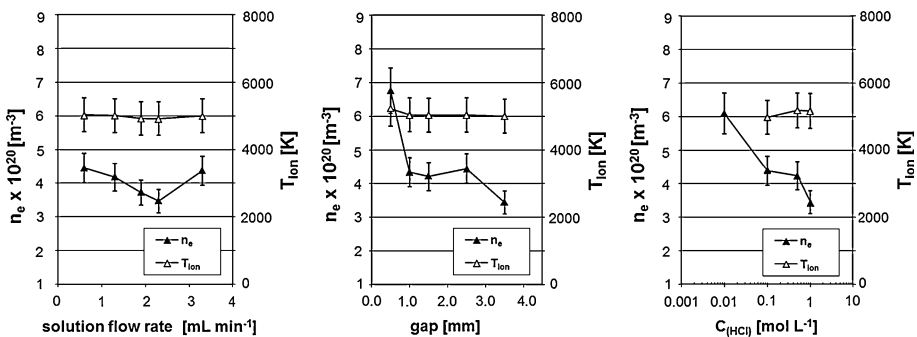
A solution of hydrochloric acid spiked with $10 \mu\text{g mL}^{-1}$ Mg ions was used and the Mg II line at 279.55 nm and Mg I line at 285.21 nm were measured (see Table 3) for the determination of the ionization temperature. Similar results of T_{ion} were obtained, if we used ratio of Mg II line at 280.27 and Mg I line at 285.21 nm. The error in the ionization temperature determination was estimated to be 500 K.

The MgII/MgI intensity ratio was also applied to calculate the degree of ionization (α_{ion}) for magnesium, using the equation [35]:

$$\log\left(\frac{\alpha_{\text{ion}}}{1 - \alpha_{\text{ion}}}\right) = \log\left(\frac{I_i}{I_a}\right) - \log\left(\frac{g_i A_i \lambda_a}{g_a A_a \lambda_i}\right) - \frac{5040}{T}(E_i - E_a) + \log\left(\frac{Z_i}{Z_a}\right) \quad (3)$$

The partition functions (Z) for atomic and ionic Mg were obtained from the polynomial tables given by Irvin [36].

The electron number density and the ionization temperature are presented in Fig. 10. The electron density decreased slightly with the HCl concentration and with the gap between electrodes. As calculated here, the electron number density was $3.4\text{--}6.8 \times 10^{20} \text{ m}^{-3}$, and it was consistent with values obtained from the Stark broadening of the H_{β} line in other atmospheric pressure glow discharge plasmas with liquid electrodes [20–22]. The ionization temperature varied over the range 4,900–5,200 K and was higher than the measured here excitation and vibrational temperatures, i.e., $T_{\text{ion}} > T_{\text{exc}} \approx T_{\text{vib}}$. Similar value of the ionization temperature was calculated Gielniak et al. [33] and Webb et al. [20] for the APGD plasma source, generated in helium atmosphere and in the contact with the liquid cathode, respectively. It should be noted, that calculated here the ionization temperature and the electron number density were significantly lower than those reported for

**Fig. 10** The electron number density and ionization temperature for the *liquid* cathode—*solid* anode system

an atmospheric pressure ICP source [27, 34]. It is mainly connected with the power of the applied plasma source and conditions of the plasma generation.

The experimental degrees of ionization for Mg were found to be: 9–14 and 19–21% for 0.1 and 0.5–1.0 mol L⁻¹ solutions of HCl, respectively. It is almost four-five times lower than in the low power capacitively coupled plasma (CCP) [35] and ICP [27] sources. The ionization degrees (α_{ion}) were compared to those calculated from the Saha equation at assumption of plasma equilibrium state. For the ionization temperature equal to 5,000 K and the electron number density assumed to be $4 \times 10^{20} \text{ m}^{-3}$, the theoretical ionization degree for Mg, (14%), was consistent with experimental values.

The values of the ionization temperature and the ionization degree are surprisingly low in our investigated plasma source and may indicate that ionization processes play an insignificant role in the production of additional electrons.

Conclusions

The investigated source with a new construction of the liquid cathode can be operated at lower flow rates (range 0.6–3.2 mL min⁻¹). A stable atmospheric pressure glow discharge was obtained under these conditions using the electrode gap and the concentration of HCl within 0.5–3.5 mm and 0.01–1 mol L⁻¹, respectively. The burning voltage in the range of 1,100–1,700 V and the current equal to 20 mA was applied to generate stable APGD plasma. The emission spectra of glow discharges were dominated by OH, N₂, H, NH, NO and O species. Strong Mg atomic lines were also observed. Weak ionic lines (Mg II) could be measured, but other ionic species as N₂⁺ emission bands and O II lines were not observed. Experimental parameters, such as the solution flow rate, the size of the gap between electrodes, and the concentrations of HCl, significantly affected the observed emission intensities. An increase in solution uptake and in concentration of HCl caused a growth of OH, H, O and N₂ intensities. Maximum spectral intensities were observed for a gap of 2.5 mm between the solid anode and the water surface.

The excitation, vibrational and rotational temperatures changed with experimental conditions. The H excitation temperature, the N₂ vibrational temperature and the OH rotational temperature varied from 3,100 to 4,200 K, from 3,100 to 4,600 K and from 2,700 to 4,100 K, respectively. For selected conditions (gap ≥ 2.5 mm, HCl concentration ≥ 0.1 mol L⁻¹), some measured temperatures were consistent (3,800–4,200 K), and $T_{\text{exc}}(\text{H}) \approx T_{\text{vib}}(\text{N}_2) \approx T_{\text{vib}}(\text{OH}) \approx T_{\text{vib}}(\text{NO}) \approx T_{\text{rot}}(\text{OH})$ within the range of experimental uncertainties of the temperature measurement. The N₂ and NO rotational temperatures were considerably lower ($\sim 1,700$ – $2,100$ K; $\sim 3,000$ K respectively), while the ionization temperature was higher ($\sim 4,900$ – $5,200$ K). The relation between the ionization, excitation, vibrational and rotational temperatures followed:

$$T_{\text{ion}} > T_{\text{exc}}(\text{H}) \approx T_{\text{vib}} \approx T_{\text{rot}}(\text{OH}) > T_{\text{rot}}(\text{NO}) > T_{\text{rot}}(\text{N}_2).$$

The electron number density and ionization degree of Mg changed over the range $(3.4 - 6.8) \times 10^{20} \text{ m}^{-3}$ and 9–21%, respectively.

For comparison, in an atmospheric pressure ICP the electron density is one to two orders higher, the Mg ionization degree reaches 95–99% while the excitation and ionization temperatures are usually between 5,000 and 10,000 K [34], so the APGD plasma is much more far from the LTE state than the ICP. However, the results indicate that deviations from local thermal equilibrium are not large and rather depend on plasma generation conditions.

Our results are comparable to other temperature measurements for similar types of discharges generated in the contact with liquid electrodes. Differences between values reported in the literature are likely caused by different conditions of the plasma generation.

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